121 Electronic Structure of the Silicon Vacancy Color Center in Diamond

Victor Waselowski¹, Tina Muller², Christian Hepp³, Jonas N. Becker³, Benjamin Pingault², Adam Gali^{4,5}, Mete Atature², Christoph Becher³ and Jeronimo R. Maze¹

¹Instituto de Fisica, Pontificia Universidad Catolica de Chile, Santiago 7820436, Chile

email address corresponding author: vhwaselo@uc.cl

The negatively charged silicon vacancy (SiV) color center in diamond has recently proven its suitability for bright and stable single photon emission. However, its electronic structure so far has remained elusive. We here explore the electronic structure by exposing single SiV defects to a magnetic field where the Zeeman effect lifts the degeneracy of magnetic sublevels. The similar responses of single centers and a SiV ensemble in a low strain reference sample prove our ability to fabricate almost perfect single SiVs, revealing the true nature of the defects electronic properties.

We model the electronic states using a group-theoretical approach yielding a good agreement with the experimental observations (see figure 1). Furthermore, the model correctly predicts polarization measurements on single SiV centers and explains recently discovered spin selective excitation of SiV defects.

The authors acknowledge support from Conicyt Program PIA No ACT1108. V.W thanks CONICYT-PCHA/Doctorado Nacional/2013-21130747 for financial support.

References

 C. Hepp, T. Muller, V. Waselowski *et al.*, Phys. Rev. Lett. **112**, 036405 (2014).

[2] J. R. Maze *et al.*, New J. Phys. **13**, 025025 (2011)

[3] A. Gali and J. R. Maze, Phys. Rev. B. 88, 235205 (2013)

[4] J.P. Goss et al., Phys. Rev. Lett. 77, 3041 (1996)

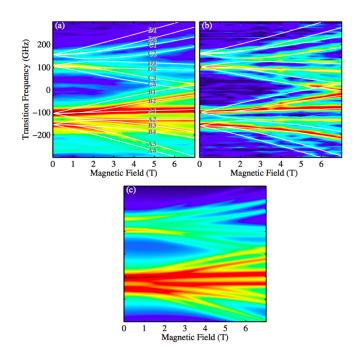


Fig. 1 Spectral fine structure splitting of (a) a SiV-ensemble (contour plot, color coding indicates peak intensity in logarithmic a.u.) and (b) single SiV-defect vs applied magnetic field [in the (001) direction]. White solid lines are calculated transitions based on the model mentioned in the text. Panel (c) displays a simulation of the fine structure lines intensity assuming dipolar transitions.

² Atomic, Mesoscopic and Optical Physics Group, Cavendish Laboratory, University of Cambridge, JJ Thomson Ave, Cambridge CB3 0HE, United Kingdom

³Fachrichtung 7.2 (Experimentalphysik), Universitt des Saarlandes, Campus E2.6, 66123 Saarbreken, Germany

⁴Department of Atomic Physics, Budapest University of Technology and Economics, H-1111 Budapest, Hungary
⁵Institute for Solid State Physics and Optics, Wigner Research Centre for Physics, Hungarian Academy of Sciences,
P.O. Box 49, H-1525 Budapest, Hungary